## Epitaxial lm grow th and m agnetic properties of Co<sub>2</sub>FeSi

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We have grown thin Insofthe Heusler compound Co2FeSiby RF magnetron sputtering. On (100)-oriented M qO substrates we nd fully epitaxial (100)-oriented and  $L_{2_1}$  ordered grow th. On A 1/0 3 (1120) substrates, the Im grow th is (110)-oriented, and several in-plane epitaxial domains are observed. The tem perature dependence of the electrical resistivity shows a power law with an exponent of 7/2 at low temperatures. Investigation of the bulk magnetic properties reveals an extrapolated saturation magnetization of 5.0  $_{\rm B}$  = fu at 0 K. The lm s on A  $l_2$ O  $_3$  show an in-plane uniaxial an isotropy, while the epitaxial Im s are m agnetically isotropic in the plane. M easurem ents of the X-ray magnetic circular dichroism of the lms allowed us to determ ine element specic m agnetic moments. Finally we have measured the spin polarization at the surface region by spinresolved near-threshold photoem ission and found it strongly reduced in contrast to the expected bulk value of 100% . Possible reasons for the reduced magnetization are discussed.

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### I. INTRODUCTION

Highly spin polarized currents and hence materials with a high spin polarization at their surface are a crucial precondition for the fabrication of spintronic devices.<sup>1</sup> In this context the most interesting materials are halfm etals. Such ferrom agnets have only electrons of one spin direction at their Ferm i edge. This property has been predicted for a num ber of materials. Photoem ission<sup>2</sup> and tunneling<sup>3</sup> experiments carried out on  $La_{2=3}Sr_{1=3}M$  nO<sub>3</sub> showed indeed half-m etallicity at low tem peratures. Unfortunately, the spin polarization at the Fermi level quickly vanishes at higher tem peratures, which prohibits the use in applications.

Further candidates for half-m etals can be found in the group of the half- and full-Heusler compounds.4,5,6 M any of those m aterials have a Curie tem perature considerably above room temperature. Half-m etallicity has been experimentally veried in NiM nSb bulk samples? But surface sensitive techniques on N M nSb thin Im s failed to demonstrate half-m etallicity. The successful deposition of epitaxial thin Ims has been reported for a number of Heusler alloys<sup>8,9,10</sup> and considerable progress in the preparation of tunneling magnetoresistance (TMR) elements with Heusler alloy electrodes has been made.<sup>11,12,13</sup> W hile at low temperatures and low bias voltages large TMR e ects have been achieved recently, the reported values at room temperature are not higher than the corresponding values obtained from conventional ferrom agnets.<sup>13</sup>

It is not straightforward that the surface region of a Heusler alloy will show the same spin-polarization as the bulk material. In principle, extrinsic as well as intrinsic mechanisms may reduce the spin polarization at the

surface. Am ong the extrinsic m echanism s, chem ical and m agnetic disorder have been discussed to play a relevant role.<sup>14,15</sup> Intrinsic mechanisms, that take place also at perfectly ordered surfaces, are for examplem agnetic uctuations and modi cations in the surface band structure with respect to the bulk one. Band structure calculations for a num ber of H eusler alloys show a reduced spin polarization at the surface layers and a dependence on the term inating layer.<sup>16</sup> In a recent publication, K olev et al<sup>17</sup> have investigated the (100) surface of N M nSb using spin-resolved appearance potential spectroscopy and found a signi cantly reduced spin asymmetry with respect to calculations based on the bulk electronic structure. Interestingly, the spin polarization results are reduced over the whole energy range of the local density of states. M oreover, the authors could exclude chem icaldisorder, structural defects at the surface, as well as overall stoichiom etric disorder as responsible mechanisms for the observed reduction of spin polarization. In another paper W ang et al.<sup>10</sup> have studied single-crystalline  $Co_2M$  nSi

In s and found for the spin polarization of electrons at the Ferm i level a maxim al value of 12% measured with spin-resolved photoem ission. They attribute this large discrepancy with the expected value of 100% to partial chem ical disorder in the  $Co_2M$  nSi lattice.

In this paper we investigate the Heusler alloy Co<sub>2</sub>FeSi. This material is especially interesting, since in a recent reinvestigation of its properties it was found to exhibit the highest Curie temperature of all materials and ful lling the Slater-Pauling rule for half-m etallic ferrom agnets.<sup>6,18</sup> The value for the saturation m agnetization in these samples is signi cantly higher than values reported in earlier publications.<sup>19,20</sup> Interestingly, LDA band structure calculations fail to reproduce this

value, instead an LDA+U form alism is required.<sup>6,18</sup> This emphasizes the importance of electron correlations in Heusler alloys with a high number of valence electrons. Important in the context of spintronic applications is the fact that these LDA+U calculations predict a halfm etallic band structure. The bulk samples showing the high values of the saturation magnetization had been annealed at 1300 K for 24 days. Such a procedure is not transferable to thin Im deposition and therefore optimization of thin Im deposition of this material is an in portant task, on which few results are published up to now. The deposition of very thin Co<sub>2</sub>FeSi lm s on G aA s by molecular beam epitaxy has been reported recently.<sup>21</sup> These samples were grown at low temperatures in order to avoid interdi usion with the reactive GaAs surface. First TMR elements have been fabricated, using sputtered, A 2-oriented electrodes.<sup>22</sup> The same paper mentions the deposition of  $L2_1$  ordered lm s, but further analysis on these Im s has not been published.

Here we report the successful grow th and full structural and m agnetic characterization of  $Co_2FeSi$  thin lm s. As the electronic states at the interface of the tunneling barrier will determ ine the elective spin-polarization we use m agnetic methods sensitive to dierent length scales due to their dierent information depths. The integral magnetic properties were determ ined with a superconducting quantum interference device (SQUID). X-ray magnetic circular dichroism (XMCD) was used to detect elementspeci c magnetic moments. The spin polarization of the surface layers was investigated by spin-resolved nearthreshold photoem ission.

### II. DEPOSITION AND STRUCTURE

W e deposited  $Co_2FeSithin$  lm s on A  $\frac{1}{2}O_3$  (1120) and M gO (100) substrates by RF m agnetron sputtering. The stoichiom etric targets were fabricated as reported in Ref. 18. The base pressure of the deposition chamber was 5 10 <sup>8</sup> m bar. W e found that for both substrates best results with respect to crystallinity were obtained with an Ar pressure of 10 <sup>2</sup> m bar and a substrate tem – perature of 700 C. The resulting deposition rate was about 5 A/s. After deposition the lm s were covered with 4 nm of A l at a tem perature of 350 C in order to prevent oxidation.

Structural analysis was carried out with a Phillips X 'Pert two-circle and a STOE four-circle di ractom eter. Figure 1 shows a Bragg scan of a  $Co_2FeSi$  In deposited on M gO. The (200) and (400) re ections of the Im are clearly visible, while impurity phases cannot be detected. The corresponding rocking curve shown in the inset of Fig. 1 has a width of 0:3, which evidences a very good out-ofplane grow th. The -scan in Fig. 2 reveals epitaxial grow th. The (010) Im plane is rotated by 45 with respect to the (010) substrate plane.

A di erent growth orientation is observed on  $A \frac{1}{2}O_3$ substrates. Here the [110] direction is perpendicular to

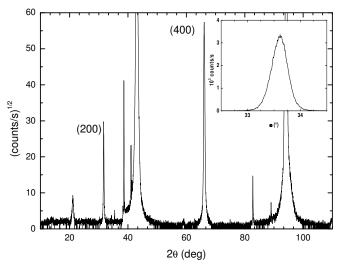


FIG.1: -2 -scan of a CoFeSi lm deposited on M gO (100). The inset shows an !-scan of the (400)-re ection. Non indexed lines are due to the substrate and impurities of the anode.

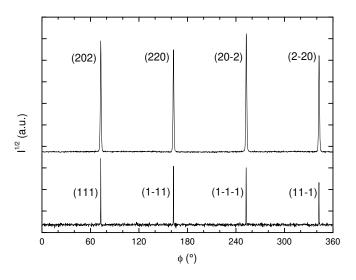


FIG.2: -scans of a (100)-oriented C  $o_2$  FeSithin  $\mbox{ Im}$  (top) and the M gO (100) substrate.

the surface. The out-of-plane rocking curves have a width of 0:1. The Bragg re ections of thinner  $\ln s$  show nite size oscillations, which indicates a at  $\ln$  surface. For these  $\ln$  swe nd three epitaxial domains. The preferred orientation, which accounts for over 90% of the scattered intensity, is (110)  $_{\rm in}$  jj(0001)\_{\rm sub}. For this alignment the m is t between  $\ln$  and substrate is very large, which may be the cause for the di erent competing in-plane domains.

The lattice constant for all  $\ln s$  was determined to be 5.64 A, which was also found in bulk samples. Further scans of the reciprocal space show the presence of (111) and (311) re ections, which reveals that the  $\ln s$  grow in the ordered L2<sub>1</sub> H eusler structure. In principle the intensity of these re ections allows the determination of the

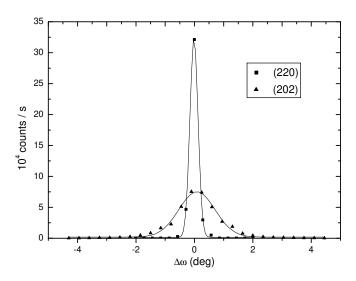


FIG. 3: !-scans of the specular (220) re ection and the o-specular (202) re ection of a lm deposited on sapphire. The area below these two curves is comparable.

degree of atom ic disorder, as it is done in standard Rietveld re nem ents of pow der patterns. How ever, the thin

Im geometry leads to additional complications. Firstly there are typically much fewer re ections experim entally accessible than in powder samples due to the geometry of the four circle di ractom eter. Secondly size and orientation e ects are stronger. The lm thickness may be very small against the lateral size of an island (or vice versa for columnar growth) leading to nite size related peak broadening of the respective re ections. A lso the rocking curve width can depend strongly on the selected re ection. For comparison with calculations one can therefore not use the maximum count rates of the re ections but needs integrated total intensities. W e com pared our measured values with the intensities obtained from PowderCellsimulations for di erent types and degrees of disorder. For lm s grown on M gO we need to introduce a disorder of 15-20% between Co and Sisites to reproduce the experim ental intensities. D espite the presence of severaldom ainswe nd for  $\ln s$  grown on A<sub>2</sub>O<sub>3</sub> nearly the same integrated intensity for equivalent re ections (see Fig. 3). Therefore we could estim ate the disorder in these

In s as well and found the same am ount of Co-Si site disorder. Due to the similar form factor of Fe and Co, disorder between these atoms is not accessible in standard x-ray analysis. The estimated values above will not necessarily be equivalent to a true atom ic disorder in the thin Im sample. While the formation of Co-Si antisites is expected to be highly unfavourable<sup>23</sup>, sputtered atoms are su ciently energetic to introduce such defects. A lso ordered domains which are smaller than the coherence length will average out and result in a strongly reduced scattering intensity of the ordering re ections.

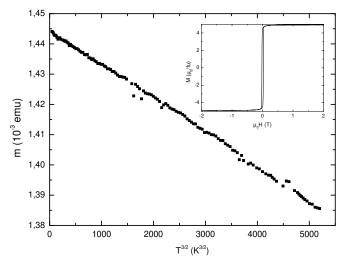


FIG.4: Tem perature dependence of the saturation m agnetization of a Co<sub>2</sub>FeSi=M gO lm. The inset shows a hysteresis loop at 4 K.

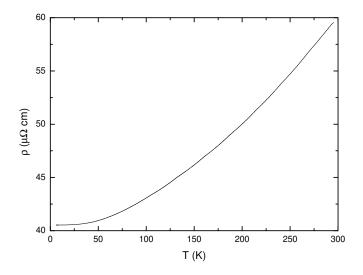


FIG.5: Tem perature dependence of the lm resistivity.

## III. MACROSCOPIC MAGNETIC AND TRANSPORT PROPERTIES

The bulk magnetization data was acquired with a Quantum Design SQUID. The results are presented in Fig. 4. The saturation magnetization is independent on the chosen substrate and can be extrapolated to 5:0  $_{\rm B}$  =fin at 0 K. Magnetization data for di erent sample alignments with respect to the external eld show an uniaxial anisotropy with the easy axis along the [110] direction. For the Co<sub>2</sub>FeSi=A  $\downarrow$ O<sub>3</sub> In s we nd H<sub>c;[110]</sub> = 15m T and H  $_{\rm c;[100]}$  = 10m T. The Ims deposited on M gO show a much smaller anisotropy, here the values for the coercitive elds are 7.5 m T and 6.8 m T, respectively. The tem perature dependence of the saturation magnetization show n in Fig. 4 exhibits a T<sup>3=2</sup> behavior over the whole investigated interval. This is in accordance to the classi-

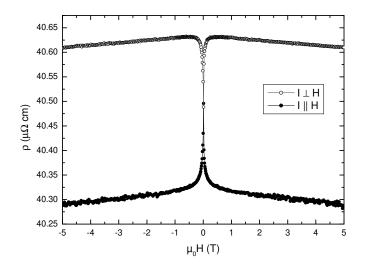


FIG . 6: M agnetoresistance of  $C \, o_2 \, FeS\, i$  at a tem perature of 4 K .

cal spin wave picture for isotropic ferrom agnets. In bulk polycrystalline material the tem perature dependence is stronger (/  $T^{1:8}$ ) and closer to the quadratic behavior of Fe bulk material. This di erence between the bulk and

In temperature dependence can result from the cuto of spin waves due to the limited  $$\rm Im\ thickness.^{24}$$ 

E lectrical transport m easurem ents were carried out using the van der Pauw method. Figure 5 dem onstrates that over the accessible tem perature range our Im s show metallic behavior. The values for residual resistance ratio  $\mathbb{R}(300 \text{ K}) = \mathbb{R}(4 \text{ K}) = 1:5$  and residual resistivity cm) are comparable to values found in thin 40 ( 0  $lm s of other H eusler alloys^{8,25,26} W e can t our data$ with a T<sup>7=2</sup> law below 70 K, at higher tem peratures we  $_{0}) / T^{1:65}$ . These exponents are to be considnd ( ered as e ective values resulting from several scattering mechanisms. For conventional ferrom agnets one would expect a T<sup>2</sup> caused by coherent one-m agnon scattering processes. But processes like incoherent scattering<sup>27</sup> or s-d-scattering  $^{28}\ {\rm m}$  ay yield di erent exponents. For halfm etallic ferrom agnets other scattering m echanism s have to be considered. In a rigid band model the absence of m inority states yields a T<sup>9=2</sup> dependence.<sup>29</sup> For a nonrigid band a T<sup>3</sup> dependence was proposed.<sup>30</sup> However, the above models do not take into account the detailed shape of the Ferm i surface, which can modify the tem perature dependence.

The magnetoresistance data was measured with the lm surface parallel to the external eld and sample current parallelor perpendicular to the eld. Figure 6 shows curves at a tem perature of 4 K. We observe an anisotropic magnetoresistance e ect with respect to the current direction, which implies the presence of spin-orbit coupling in our lm s. The spontaneous resistivity anisotropy  $\binom{k}{k}$ ?  $=(1=3 \ k+2=3 \ ?)$  0.8% is small and negative. This e ect is dom inating the low eld magnetoresistivity shows a linear dependence on the applied eld. At 4 K

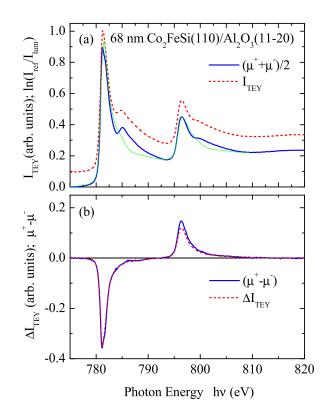
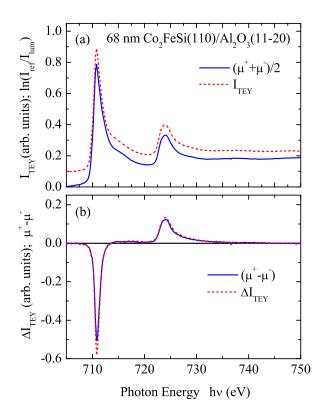


FIG.7: (Color online) Co XAS (a) and XMCD (b) spectra obtained by transm ission m easurements (full lines) and as determined by TEY (dashed lines) at 300 K of a 68 nm thick  $Co_2FeSi(110)$  Heusler alloy lm grown on  $Al_2O_3$  (1120) and capped by 4 nm Al. The TEY XAS spectra were normalized to the value of the transm ission XAS value at the  $L_3$  m axim um. The thin green line is an elemental Co reference.

the slope has a value of 45n cm = T. It increases up to 25n cm = T at 300 K. These results are comparable to conventional ferrom agnets.<sup>31</sup> Therefore we must assume a signi cant contribution of spin- ip scattering to the magnetoresistance.

# IV . M ICROSCOPIC MAGNETIZATION $(X \mbox{ M CD})$

U sing X-ray magnetic circular dichroism (XMCD) in the X-ray absorption spectroscopy (XAS) we gain quantitative information on element-speci c spin and orbital magnetic moments. The XAS experiments were performed at the UE56/1 - SGM beam line at the German synchrotron light source BESSY II (Berlin). While the incident photon ux was monitored by a Au net, we simultaneously measured the transmission XAS signal and the total electron yield (TEY) of the photoem itted electrons.<sup>32</sup> TEY was measured via the sam ple current. W hile the transmission signal integrates absorption properties along the lm normal and thus represents the bulk properties of the lm, the TEY signal stems from the upper interface region limited by the electron escape depth.



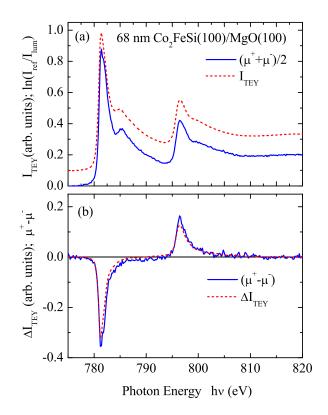


FIG.8: (Color online) Fe XAS (a) and XMCD (b) spectra obtained by transm ission measurements (full lines) and as determined by TEY (dashed lines) at 300 K of a 68 nm thick  $Co_2FeSi(110)$  Heusler alloy lm grown on  $Al_2O_3$  (1120) and capped by 4 nm Al. The TEY XAS spectra were normalized to the value of the transm ission XAS value at the  $L_3$  maximum.

Therefore, the TEY signal re ects properties of the upper interface. The sample was shielded by a conducting tube on a positive bias voltage (100 V) in order to collect all electrons. For the transm ission XAS signal the photon ux transmitted through the thin Heusler Imswas detected via X -ray lum inescence in the A  $\frac{1}{2}$ O  $_3$  and M gO substrates.33 The light intensity in the visible wavelength range (VIS) escaping at the substrate edge wasm easured by a GaAs - photodiode. The GaAs - photodiode was protected by a transparent cap layer in order to prevent detection of X-ray uorescence light from the sample surface. An external magnetic eld of 1.6 Tesla, which is su ciently large to saturate the sample magnetization, was applied perpendicular to the lm surface. We kept the X -ray polarization constant and ipped the magnetic eld to determ ine the XMCD-signal, XMCD was mea-

sured at room temperature. Samples were capped by a protective 4 nm thick Allayer for these experiments.

F igures 7 and 8 com pare the transm ission X A S and the X-ray absorption at the characteristic C o and Fe edges, respectively, as determined by TEY for a 68 nm thick C  $o_2$ FeSi(110) H eusler alloy lm grown on A  $\frac{1}{2}O_3$  (1120). A ssum ing that the lum inescence signal of the substrate  $I_{lum}$  is proportional to the transm itted X-ray intensity,

FIG.9: (Color online) Co XAS (a) and XMCD (b) spectra obtained by transm ission measurements (full lines) and as determined by TEY (dashed lines) at 300 K of a 68 nm thick  $Co_2FeSi(100)$  Heusler alloy lm grown on MgO (100) and capped by 4 nm Al. The TEY XAS spectra were normalized to the value of the transm ission XAS value at the  $L_3$  maximum.

the X-ray absorption coe cient can be calculated using the equation  $(h) = \ln [I (h)] = I_{ref} (h) = J_{ref} (h)$ is the thickness of the lm . The reference spectra  $I_{ref}$  (h) wasm easured by the bare substrate crystal and found to increase linearly with the photon energy.  $I_{ref}$  (h ) was then norm alized at the pre-edge region of the corresponding element (equivalent to an in nitely large penetration depth). The simultaneously measured TEY absorption spectra are shown in Figs. 7 and 8 for com parison. A fter subtracting the background signal the TEY-XAS spectra were multiplied by a constant factor in order to achieve at the  ${\tt L}_3$  maximum . The  $(I_{TEY}^{+} + I_{TEY}) = + +$ corresponding normalization factor was also applied to the XMCD signal in order to compare both signals. The TEY spectra show no oxidation features indicating that the Allayer protects the surface.

Transmission and TEY Co XAS signals (Fig. 7a) show the typical features observed already for bulk  $Co_2CrA$  land  $Co_2FeSiH$  eusler alloy.<sup>18,34</sup> The general appearance of both spectra are similar. Even the step jump between pre- and post-edge intensity is almost equal, in contrast to the previously investigated case of  $Co_2Cr_{0.6}Fe_{0.4}A l/A l_2O_3$  Im s.<sup>32</sup> This indicates similar values for the number of d-holes in the bulk and at

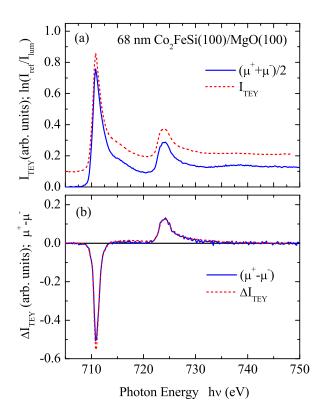


FIG.10: (Color online) Fe XAS (a) and XMCD (b) spectra obtained by transm ission measurements (full lines) and as determined by TEY (dashed lines) at 300 K of a 68 nm thick  $Co_2FeSi(100)$  Heusler alloy lm grown on MgO (100) and capped by 4 nm Al. The TEY XAS spectra were normalized to the value of the transm ission XAS value at the  $L_3$  maximum.

the interface. C om pared to the XAS signal of pure Co, the signal drops less steep after the  $L_{2=3}$  edge and shows an extra m axim um at about 4 eV above the edges.<sup>34,35</sup> This extra m axim um is much more pronounced for the  $L_3$  edge than for the  $L_2$  edge because of the typical lifetime broadening. The extra peak was explained by a hybridization of C o d-band states with sp-states of the main group element. We have observed that this extra peak vanishes for disordered or selectively oxidized H eusler alloys.<sup>34</sup> The fact that the extra peak is more pronounced for the transmission signal compared to TEY might indicate that the bulk of the lm shows a higher degree of local atom ic order than the surface region.

The XMCD signals for transmission and TEY do not show any pronounced di erences for lms grown on A $\downarrow$ O<sub>3</sub>. Element speci c magnetic moments were derived by a sum-rule analysis assuming numbers of dholes n<sub>d</sub> (Fe) = 3:4, n<sub>d</sub> (Co) = 2:5 as reported for the pure elements.<sup>36</sup> Theoretically predicted values of n<sub>d</sub> in the Heusler compound deviate slightly from the pure element data for the case of an LDA based calculation: n<sub>d</sub> (Fe) = 3:5, n<sub>d</sub> (Co) = 2:3.<sup>37</sup> Sm aller values in particular for Co were reported for a calculation considering electron correlation (LDA+U) (n<sub>d</sub> (Fe) = 3:2, TABLE I: Element specic moments for Fe and Co in the  $Co_2FeSi(110)$  Im s grown on  $Al_2O_3$  (1120) as derived from the sum rules from total electron yield (TEY) and transm ission (TM) data. The specic number of d-holes were set to  $N_{d}$  (Co) = 2:49,  $N_{d}$  (Fe) = 3:39. Error bars for the XM CD values, excluding errors of N  $_{\rm d}$  or P , are 0:1  $_{\rm B}$  for the spin m om ent and  $0.02_{\rm B}$  for the orbitalm om ent. The sum m arized magnetic moment per formula unit  $_{sum} = 2 _{Co} + _{Fe}$  is com pared to the magnetic moment per form ula unit measured by SQUID magnetom etry at 300 K . The values from the XMCD experim ent are approxim ately 10% larger. The main uncertainty results from the assumed number of d-holes, which is probably not exactly the sam e as in elemental Co. Furtherm ore, the XMCD data does not take into account interstitial m om ents and the m om ent at Si sites, which have theoretically a magnitude of 0.2  $_{\rm B}$  and 0.1  $_{\rm B}$  respectively, and are aligned antiparallel to the Fe and Comoments.<sup>18</sup> Considering the general accuracy of the sum -rule analysis, XMCD and m agnetom etry data agree with each other.

A ½O 3 (1120)	Co	Fe	Co <sub>2</sub> FeSi
$_{\rm spin}$ (TEY)( $_{\rm B}$ )	1.13	2.47	4.73
$_{\rm spin}$ (T M )( $_{\rm B}$ )	1,25	2.43	4.93
$_{\rm orb}$ (TEY)( $_{\rm B}$ )	0.14	0.10	0.38
$_{\rm orb}$ (T M )( $_{\rm B}$ )	0.11	0.07	0.29
$_{\rm sum}$ (TEY)( $_{\rm B}$ )	1,27	2.57	5.11
$_{\rm sum}$ (T M )( $_{\rm B}$ )	1.36	2.50	5.22
<sub>SQUD</sub> ( <sub>B</sub> )			4.8

TABLE II: E lem ent speci c m om ents for Fe and Co in the  $Co_2FeSi(100)$  lm s grow n on M gO (100) as derived from the sum rules (see Tab. I).

M gO (100)	Сo	Fe	Co <sub>2</sub> FeSi
$_{\rm spin}$ (TEY)( $_{\rm B}$ )	1.07	2.46	4.60
$_{\rm spin}$ (T M )( $_{\rm B}$ )	1,28	2.46	5.02
$_{\rm orb}$ (TEY)( $_{\rm B}$ )	0.04	0.05	0.13
$_{\rm orb}$ (T M )( $_{\rm B}$ )	0.13	0.12	0.38
$_{\rm sum}$ (TEY)( $_{\rm B}$ )	1.11	2.51	4.73
$_{\rm sum}$ (TM )( $_{\rm B}$ )	1.41	2.58	5.40
<sub>SQUID</sub> ( <sub>B</sub> )			4.8

 $n_d$  (C o) = 1:8).<sup>18</sup> An experimental determination of  $n_d$  results from an integration of the spin-averaged absorption signal after subtraction of a step function.<sup>36</sup> A comparison with the corresponding value that we measured for a pure element reference sample (see Fig. 7a) reveals that  $n_d$  (C o) is almost equal for pure C o and C o in C o<sub>2</sub>FeSi. We estimate that the systematic error due to background subtraction is less than 10 % for this mea-

surement. This result justimes the usage of Co and Fe bulk values for the determination of magnetic moments.

W e corrected the XAS spectra for saturation e ects using the X-ray penetration depth as determined from the transm ission signal and assuming an electron escape depth of  $_{e}$  = 25 A.<sup>36</sup> Neglecting the saturation e ect results in apparently smaller spin and orbital moments, much more pronounced for orbital moments. However, in the present case the correction is sm all because the elem ents are diluted in the Heusler alloy.<sup>32</sup> For calculation of the spin moment we neglected the magnetic dipolar asymmetry. This is justied since we did not nd an angular dependence of the spin moment. The element speci c m om ents are sum m arized in Tab. I. N ote, that the error bars given for the spin moment consider only errors due to the integration of the spectra and not errors in the number of d-holes or in the polarization value of the X-ray light. Interestingly, for  $\ln s$  grown on A  $\frac{1}{2}O_3$ the surface and bulk magnetic moments do not show a di erence within our error lim its.

Sim ilar results obtained for a 68 nm thick C o<sub>2</sub> FeSi(100) Heusleralloy Im grown on M gO (100) are shown in Fig.9 and Fig. 10. Also for the (100) oriented Im s the extra peak in the Co absorption signal appears som ew hat smaller in the TEY signal compared to the transmission signal. The di erence is slightly more pronounced com pared to the (110) oriented Im. We also observe a signi cant di erence in the Co XMCD signal. W hile the asym m etry of the transm ission signal is equal to the value measured for the (110) oriented Im the TEY XMCD signal is signi cantly smaller both at the  $L_3$  and  $L_2$  edge. The sum rule analysis consequently results in smaller values for the surface magnetic moment compared to the bulk value (see Tab. II). Tentatively we attribute this e ect to a less well ordered interface region at the Al cap layer of (100) oriented Im s com pared to (110) oriented Im s. An even larger decrease of surface m om ent with respect to the bulk value was observed in the case of  $Co_2 Cr_{0:6}Fe_{0:4}A I/A I_2O_3$  (1120) Im s<sup>32</sup>

The sum marized magnetic moments  $_{sum}$  per form ula unit resulting from XMCD appear smaller than the integral value determ ined by magnetom etry. A slightly larger value could be expected, since the antiparallel aligned interstitial and Simoments are not considered in the XMCD data. Moreover, the number of d-holes assumed here m ight be overestimated because theoretical values for  $n_d$  are slightly smaller.<sup>18,37</sup>

The absolute values of the element-speci c m agnetic m om ents are smaller than expected for a half-m etallic m aterial and smaller than those determ ined for the corresponding bulk material. A band-structure calculation considering electron correlation<sup>18</sup> predicts values of (Fe) = 3:3 <sub>B</sub>, (Co) = 1:5 <sub>B</sub> and a magnetization of = 6:0 <sub>B</sub>/fu. One expects an integer value for the num - ber of <sub>B</sub>/fu for a half-m etallic H eusler alloy and indeed a magnetization of = 6:0 <sub>B</sub>/fu was experimentally con m ed for bulk samples of Cq.FeSi.<sup>18</sup>

### V. SURFACE SPIN POLARIZATION

W e now discuss the spin-resolved photoem ission spectra (SRPES) measured from our Co<sub>2</sub>FeSi/AbO<sub>3</sub> and Co<sub>2</sub>FeSi/MgO thin lm s. The sam ples were mounted in an ultrahigh vacuum (UHV) chamber with a base pressure below 10<sup>10</sup> m bar. Prior to the measurem ents, the Alprotecting cap layer was rem oved under UHV conditions in situ by sputtering with 500 eV Art ions. Subsequently, the surface was prepared by repeated cycles of sputtering and prolonged annealing at 570 K .C leanliness was checked by means of Auger electron spectroscopy, geom etrical order by means of low energy electron di raction (LEED). Only the Co<sub>2</sub>FeSi/MgO lm s, being fully epitaxial, revealed a LEED pattern. A representative LEED pattern for such lm s is shown in Fig. 11. The picture was recorded at 318 eV prim ary electron energy and demonstrates a clear fourfold symmetry in correspondence with the cubic bulk lattice.

The SRPES were recorded at 300K using the spolarized 4th harm onic (photon energy 5.9 eV) of a narrow band, pulsed T iSapphire oscillator (Spectra-physics, T sunam i) created by sequential frequency doubling in two 0.2mm thick beta barium borate (BBO) crystals. The incident light was focused onto the sam ple with an angle of 45 with respect to the surface normal. The photoem itted electrons were analyzed in normal em ission geometry by a commercial cylindrical sector analyzer (Focus CSA 300) equipped with an additional spin detector based on spin-polarized low -energy electron di raction (Focus SPLEED). The achieved energy resolution is 150m eV, the acceptance angle of the analyzer is 13. For the SRPES measurements the Im s were rem anently magnetized by an external in-plane magnetic

ekd. Figure 12 (a) and (c) show the SRPES recorded from the Co<sub>2</sub>FeSi/A  $\downarrow$ O<sub>3</sub> and Co<sub>2</sub>FeSi/M gO  $\,$  Im s, respectively. The spectra show the Ferm i level (E  $_{\rm F}$ ) and a structureless behavior up to the low energy cuto  $\,$ . This is in qualitative agreement with band structure calculations performed with LDA+U and presented in Ref. 18. However, those calculations predict for binding energies between approximately 2 eV and 0.5 eV a higher density of states for m inority than for majority electrons, and a band gap for m inority electrons in the energy range between 0.5 eV and E  $_{\rm F}$ . One would expect a 100% polarization between 0.5 eV and E  $_{\rm F}$  and a sudden drop to negative spin polarization for binding energies between 2 eV and 0.5 eV .

However, in the measured spin up and spin down spectra shown in Figs. 12 (a) and (c) the majority-spin spectrum has a higher intensity than the minority-spin spectrum over the whole energy range and for both lms. This results in a positive spin-polarization, depicted in Fig. 12 (b) and (d). In more detail, the curves show a maximal spin polarization of 4% for the  $Co_2FeSi/A \ge 0_3$ 

In and of 12% for the C  $_{\rm Q}$  FeSi/M gO In , respectively. For energies close to E  $_{\rm F}$  we have P (E  $_{\rm F}$ ) 0% and P (E  $_{\rm F}$ ) 6% , respectively. These values are drastically

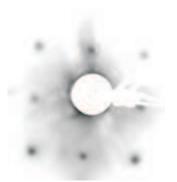


FIG.11: LEED pattern of C  $_{\rm 2}FeS\,i/M$  gO, taken at 318eV prim ary electron energy. The pattern demonstrates a clear fourfold symmetry.

reduced with respect to the expected 100% in case ofhalfm etallic behavior as predicted in Ref. 18. Sim ilar values have been reported previously by W ang et al. for single-crystalline C o<sub>2</sub>M nSi  $\,$  Im s.<sup>10</sup> In accordance with the results of K olev et al.<sup>17</sup> we also observe that the the discrepancy with theory is not restricted to E $_{\rm F}$ , but extends up to 1.5eV below E $_{\rm F}$ . Further studies of a C o<sub>2</sub>FeSi/M gO

In perform ed with spin- and time-resolved photoem ission, have shown that the observed reduction of spin polarization is not con ned to the outerm ost surface layer, but extends at least 4 { 6 nm into the sam  $ple^{38}$ .

In contrast the XMCD and SQUID experiments showed only a comparatively sm all reduction of the expected values. This discrepancy results from the particular band structure of this Heusler compound. The halfm etallic behavior of the perfectly ordered com pound originates from a complete absence of spin m inority states at  $E_{\rm F}$  and a sm all but nonvanishing density of majority states. As discussed for the sim ilar Co<sub>2</sub>M nSi com pound a small degree of disorder can introduce spin minority states at E<sub>F</sub>. Especially Co antisite defects act in this direction and will have a dram atic e ect on spin polarization at E<sub>F</sub>.<sup>23</sup> W e found in our XMCD experiments a pronounced double peak structure at the Co-edges and also clearly observed the  $L2_1$  order peaks in the x-ray data. B oth observations are usually taken as proof for an  $L2_1$ ordered sample. But from our analysis of the x-ray peak intensities we concluded on atom ic site disorder. Here the surface has been treated by sputter cleaning, which can introduce additional atom ic disorder. O by jously the disorder level seem s to be su cient to destroy halfm etallicity at  $E_F$  in the photoem ission experiment. However, XMCD and SQUD experiments probe integrated densities of states above and below  $E_{\rm F}$  , respectively. The sm all density of states close to  $E_F$  does not contribute much to the integral values and we nd correspondingly

only sm all reductions of the magnetic moments.

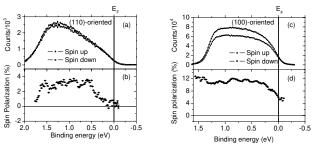


FIG.12: (a) and (c) Spin-resolved photoem ission spectra of the  $Co_2FeSi/A \downarrow O_3$  and  $Co_2FeSi/M gO$  lm s. The excitation source was the fourth harmonic of a T is apphire oscillator, with photon energy of 6.0 eV (see text). Triangles (squares) indicate m a prity (m inority) spin spectra. (b) and (d) Spin polarization calculated from the curves in (a) and (c), respectively.

#### VI. SUMMARY

We have successfully deposited thin Im softhe potentially half-m etallic m aterial C o2 FeSi, which grow sepitaxially in the L2<sub>1</sub> full Heusler structure. Despite the good crystal quality, the bulk value of the saturation magnetization is reduced in comparison with the value from polycrystalline bulk sam ples. This might be caused by an incom plete atom ic order with respect to the L21 structure in our Ims. Using methods sensitive to di erent length scales we nd that the reduction is not hom ogeneous over the Im thickness. Magnetic moments are lowest at the interface to the A l-cap layer as can be deduced from comparison of transmission and total electron yield signals in XMCD experiments. Using spin resolved photoem ssion experiments we failed to establish a high spin polarization at  $E_F$  . Due to the high energy resolution these experiments will be more sensitive to disorder e ects which introduce m inority states at  $E_F$ . The unavoidable sputter cleaning of the sam ple, how ever, could introduce a higher degree of disorder at the free surface.

From our results we conclude that optim ization of the atom ic ordering will be the most in portant factor in order to establish a high spin polarization in  $Co_2FeSi$  Ims.

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